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PATENT ASSIGNMENT

Electronic Version v1.1 Stylesheet Version v1.1

SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	ASSIGNMENT

CONVEYING PARTY DATA

Name	Execution Date
PLANAR SYSTEMS, INC.	12/11/2012

RECEIVING PARTY DATA

Name:	BENEQ OY
Street Address:	Ensimmainen savu 2
City:	Vantaa
State/Country:	FINLAND
Postal Code:	FI-01510

PROPERTY NUMBERS Total: 1

Property Type	Number
Patent Number:	7198820

CORRESPONDENCE DATA

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ATTORNEY DOCKET NUMBER: 1032221-000075

NAME OF SUBMITTER: Vanessa L. Weedon

Total Attachments: 3

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> PATENT REEL: 029857 FRAME: 0599

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ASSIGNMENT OF PATENT RIGHTS

For good and valuable consideration, the receipt of which is hereby acknowledged, PLANAR SYSTEMS, INC, an Oregon corporation having an address at 1195 NW Compton Dr., Beaverton, Oregon 97006-1992 ("Assignor"), has sold, assigned, transferred and conveyed, and does hereby sell, assign, transfer, and convey, unto BENEQ OY, a company organized under the laws of Finland, having an address at Ensimmäinen savu 2, FI-01510 Vantaa, Finland ("Assignee"), or its designees, all of Assignor's right, title, and interest that exist today and may exist in the future in and to all of the following (collectively, the "Patent Rights"):

- (a) the patent applications and patents listed below (the "Patents");
- (b) all patent applications, patents or other governmental grants or issuances (i) to which any of the Patents directly or indirectly claims priority and/or (ii) for which any of the Patents directly or indirectly forms a basis for priority;
- (c) reissues, reexaminations, extensions, continuations, continuations-in-part, continuing prosecution applications, requests for continuing examinations, and divisions of any item in the foregoing categories (a) and (b);
- (d) foreign patents, patent applications, and counterparts relating to any item in the foregoing categories (a) through (c), including, without limitation, certificates of invention, utility models, industrial design protection, design patent protection, and other governmental grants or issuances;
- (e) rights to apply in any or all countries of the world for patents, certificates of invention, utility models, industrial design protections, design patent protections, or other governmental grants or issuances of any type related to any item in the foregoing categories (a) through (d), including, without limitation, under the Paris Convention for the Protection of Industrial Property, the International Patent Cooperation Treaty, or any other convention, treaty, agreement, or understanding; and
- (f) causes of action (whether currently pending, filed, or otherwise) and other enforcement rights under, or on account of, any of the Patents and/or any item in any of the foregoing categories (a) through (e), including, without limitation, all causes of action and other enforcement rights for (i) damages, (ii) injunctive relief, and (iii) other remedies of any kind for past, current, and future infringement.

Patent/Applen No.	Country	Issue/Filing	Title '5
	r i jan	Date (m/d/v)	TO LETTING FOR MICEO
ZL560757	China	10/21/2009	CONFORMAL COATINGS FOR MICRO-
(pub. CN100551686C)			OPTICAL ELEMENTS
DE112004000587.6	Germany	3/22/2004	CONFORMAL COATINGS FOR MICRO-
	•		OPTICAL ELEMENTS
DE112004001147.7	Germany	6/28/2004	DIAPHRAGM VALVE FOR ATOMIC LAYER
			DEPOSITION
JP4011126	Japan	9/14/2007	BLACK ELECTRODE TFEL DISPLAY
JP4711588	Japan	4/1/2011	THIN FILM ELECTROLUMINESCENT
	•		PHOSPHOR
GB2407586	U.K.	3/22/2006	PRECURSOR MATERIAL DELIVERY
1			SYSTEM FOR ATOMIC LAYER
			DEPOSITION
GB2409180	U.K.	1/25/2006	HIGH CONDUCTIVITY PARTICLE FILTER

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PATENT REEL: 029857 FRAME: 0600

Patent/Appl/fr No.	Country.	Tssue/Filing.ra	Title + 100
A STATE OF THE STA	Turk in the	Date (m/d/y)	一种,这种人的
GB2415967	U.K.	8/2/2006	PRECURSOR MATERIAL DELIVERY
			SYSTEM FOR ATOMIC LAYER
			DEPOSITION
GB2418005	U.K.	11/1/2006	DIAPHRAGM VALVE FOR ATOMIC LAYER
			DEPOSITION TO THE PROPERTY OF
GB2417218	U.K.	7/12/2006	HIGH CONDUCTIVITY PARTICLE FILTER
GB2426808	U.K.	3/28/2007	DIAPHRAGM VALVE FOR ATOMIC LAYER
			DEPOSITION
US5,504,389	U.S.	4/2/1996	BLACK ELECTRODE TFEL DISPLAY
US5,505,986	U.S.	4/9/1996	MULTI-SOURCE REACTIVE DEPOSITION
			PROCESS FOR THE PREPARATION OF
			BLUE LIGHT EMITTING PHOSPHOR
			LAYERS FOR AC TFEL DEVICES
US5,598,059	U.S.	1/28/1997	AC TFEL DEVICE HAIVING A WHITE
			LIGHT-EMITTING MULTILAYER
			PHOSPHOR
US5,661,364	U.S.	8/26/1997	SIMPLIFIED MECHANICAL PACKAGE FOR
			EL DISPLAYS
US5,939,825	U.S.	8/17/1999	ALTERNATING CURRENT THIN FILM
			ELECTROLUMINESCENT DEVICE HAVING
			BLUE LIGHT EMITTING ALKALINE EARTH
			PHOSPHOR PHOSPHOR
US5,986,628	U.S.	11/16/1999	FIELD SEQUENTIAL COLOR AMEL
			DISPLAY
US6,043,602	U.S.	3/28/2000	ALTERNATING CURRENT THIN FILM
			ELECTROLUMINESCENT DEVICE HAVING
			BLUE LIGHT EMITTING ALKALINE EARTH
			PHOSPHOR
US6,072,198	U.S.	6/6/2000	ELECTROLMINESCENT ALKALINE-EARTH
			SULFIDE PHOSPHOR THIN FILMS WITH
			MULTIPLE COACTIVATOR DOPANTS ELECTROLUMINESCENT PHOSPHOR THIN
US6,169,359	U.S.	1/2/2001	FILMS WITH INCREASED BRIGHTNESS
			THAT INCLUDES AN ALKALI HALIDE ELECTROLUMINESCENT PHOSHOR THIN
US6,242,858	U.S.	6/5/2001	1
		5 10 10 00 C	FILMS AMEL DEVICE WITH IMPROVED OPTICAL
US6,414,439	U.S.	7/2/2002	PROPERTIES
		0.117170000	THIN FILM ELECTROLUMINESCENT
US6,451,460	U.S.	9/17/2002	
		1/7/0000	DEVICE AMEL DEVICE WITH IMPROVED OPTICAL
US6,504,312	U.S.	1/7/2003	1
		1111/2000	PROPERTIES DISDLAY
US6,507,156	U.S.	1/14/2003	DISPLAY ORGANIC LIGHT EMITTING DEVICE
US6,608,448	U.S.	8/19/2003	DIAPHRAGM VALVE FOR HIGH-
US6,907,897	U.S.	6/21/2005	TEMPERAURE PRECURSOR SUPPLY IN
			ATOMIC LAYER DEPOSITION
The state of the s		0/20/2007	HIGH CONDUCTIVITY PARTICLE FILTER
US6,936,086	U.S.	8/30/2005	HIGH-SPEED DIAPHRAGM VALVE FOR
US6,941,963	U.S.	9/13/2005	ATOMIC LAYER DEPOSITION
1	Į.	1	ATOMIC LATER DEFORTION

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Påtent/Appl'n'No:	Country	Issue/Filing Daie (m/d/y)	
US7,021,330	U.S.	4/4/2006	DIAPHRAGM VALVE WITH RELIABILITY ENHANCEMENTS FOR ATOMIC LAYER DEPOSITION
US7,141,095	U.S.	11/28/2006	PRECURSOR MATERIAL DELIVERY SYSTEM FOR ATOMIC LAYER DEPOSITION
US7,191,793	U.S.	3/20/2007	DIAPHRAGM VALVE FOR ATOMIC LAYER DEPOSITION
US7,198,820	U.S.	4/3/2007	DEPOSITION OF CARBON- AND TRANSITION METAL-CONTAINING THIN FILMS
US7,294,360	U.S.	11/13/2007	CONFORMAL COATINGS FOR MICRO- OPTICAL ELEMENTS

IN TESTIMONY WHEREOF this Assignment of Patent Rights is executed at Beaverton,

Oregon, United States of America on 11 NECEMBER ZO! Z

ASSIGNOR

By: PLANAR SYSTEMS, INC.

Name: Stephen M. Going

Title: Senior Vice President, General Counsel &

Secretary

Acknowledged:

ASSIGNEE

By: BENEQ OY

Name: Olli Pekonen Title: IPR Director 30

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RECORDED: 02/22/2013